

SEMINAR ON APPLICATIONS FOR AUTHORISATION

28-29 APRIL 2014

ECHA CONFERENCE CENTRE, ANNANKATU 18, HELSINKI, FINLAND

FINAL PROGRAMME

Monday 28 April

13:00-13:30	REGISTRATION OF PARTICIPANTS	
13:30	Opening - Matti Vainio, ECHA	
Session I		
CONTEXT, CONTENT OF APPLICATIONS AND EVALUATION BY COMMITTEES		
13:40	Why should you apply for an authorisation? - Matti Vainio, ECHA	
14:00	Content and submission of applications- Peter Simpson, ECHA	
14:20	Process and support (including timelines, submission windows, PSIS, support pages, Q&As) – <i>Denis Mottet, ECHA</i>	
14:40	Evaluation of Applications by Committees (including Trialogue) – <i>Tim Bowmer</i> , <i>ECHA</i>	
15:00 Coffee break		
15:25	Answers to questions and discussion*	
Session II		
DESCRIPTION OF USES, ANALYSIS OF ALTERNATIVES AND SOCIO-ECONOMIC ANALYSIS		
16:15	Description of uses for authorisation / Broad information on uses - <i>Thierry Nicot</i> , <i>ECHA</i>	
16:40	Analysis of Alternatives and Socio-economic Analysis in Authorisation – Kalle Kivelä, ECHA	
17:00	CSR, SEA and AoA for defining the scope of the application – Hugo Waeterschoot, Eurometaux	
17:20	Answers to questions and discussion*	
18:30	Drink	
19:00	End of the first day	
19:30	Informal dinner	

^{*} The discussion will be moderated by Erwin Annys (Cefic) and Hugo Waeterschoot (Eurometaux)



Tuesday 29 April

Session III		
PUBLIC CONSULTATION AND INDUSTRY PERSPECTIVE		
09:00	Public consultation on alternatives - Elina Liopa, ECHA	
09:15	"Unauthorised" myths of Applications for Authorisation – Erwin Annys, Cefic	
09:35	Joint versus Individual applications and Downstream User Considerations — Hugo Waeterschoot, Eurometaux	
10:00	Experience from a Downstream User point of view - Elke Van Asbroeck, Apeiron-Team NV	
10:25 Filling in feedback questionnaire and coffee break		
Session IV		
DISCUSSION WITH PARTICIPANTS AND CONCLUSIONS		
10:55	Key issues for discussion – Markus Berges, ECHA	
11:15	Answers to questions and discussion*	
12:00	Conclusions – Matti Vainio, ECHA	
12:15	End of the seminar	

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